# International Provise **ICR** Rectifier REPETITIVE AVALANCHE AND dv/dt RATED **HEXFET® TRANSISTOR**

# IRHN2C50SE IRHN7C50SE N-CHANNEL

# SINGLE EVENT EFFECT (SEE) RAD HARD

#### 600 Volt, 0.60 $\Omega$ , (SEE) RAD HARD HEXFET

International Rectifier's (SEE) RAD HARD technology HEXFETs demonstrate virtual immunity to SEE failure. Additionally, under **identical** pre- and post-radiation test conditions, International Rectifier's RAD HARD HEXFETs retain **identical** electrical specifications up to 1 x 10<sup>5</sup> Rads (Si) total dose. No compensation in gate drive circuitry is required. These devices are also capable of surviving transient ionization pulses as high as 1 x 10<sup>12</sup> Rads (Si)/Sec, and return to normal operation within a few microseconds. Since the SEE process utilizes International Rectifier's patented HEXFET technology, the user can expect the highest quality and reliability in the industry.

RAD HARD HEXFET transistors also feature all of the well-established advantages of MOSFETs, such as voltage control, very fast switching, ease of paralleling and temperature stability of the electrical parameters.

They are well-suited for applications such as switching power supplies, motor controls, inverters, choppers, audio amplifiers and high-energy pulse circuits in space and weapons environments.

#### Product Summary

Part Number	BVDSS	RDS(on)	ID
IRHN2C50SE	600V	0.60Ω	10.4A
IRHN7C50SE	000 v	0.0032	10.4A

#### Features:

- Radiation Hardened up to 1 x 10<sup>5</sup> Rads (Si)
- Single Event Burnout (SEB) Hardened
- Single Event Gate Rupture (SEGR) Hardened
- Gamma Dot (Flash X-Ray) Hardened
- Neutron Tolerant
- Identical Pre- and Post-Electrical Test Conditions
- Repetitive Avalanche Rating
- Dynamic dv/dt Rating
- Simple Drive Requirements
- Ease of Paralleling
- Hermetically Sealed
- Surface Mount
- Light-Weight

### **Absolute Maximum Ratings**

#### **Pre-Radiation**

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	Parameter	IRHN2C50SE, IRHN7C50SE	Units
$I_D @ V_{GS} = 12V, T_C = 25^{\circ}C$	Continuous Drain Current	10.4	
$I_D @ V_{GS} = 12V, T_C = 100^{\circ}C$	Continuous Drain Current	6.5	A
IDM	IDM Pulsed Drain Current ①		1
P <sub>D</sub> @ T <sub>C</sub> = 25°C	Max. Power Dissipation	150	W
	Linear Derating Factor	1.2	W/K 5
VGS	Gate-to-Source Voltage	±20	V
EAS	Single Pulse Avalanche Energy 2	500	mJ
I <sub>AR</sub>	Avalanche Current ①	10.4	A
EAR	Repetitive Avalanche Energy ①	15	mJ
dv/dt	Peak Diode Recovery dv/dt 3	3.0	V/ns
Тј	Operating Junction	-55 to 150	
TSTG	Storage Temperature Range		
Package Mounting Surface Temperature		300 (for 5 seconds)	°C
	Weight	2.6 (typical)	g

# IRHN2C50SE, IRHN7C50SE Devices

	Parameter	Min.	Тур.	Max.	Units	Test Conditions		
BVDSS	Drain-to-Source Breakdown Voltage	600	—	—	V	VGS = 0V, ID = 1.0 mA		
$\Delta BV_{DSS}/\Delta T_{J}$	Temperature Coefficient of Breakdown Voltage	—	0.45	—	V/°C	Reference to 25°C, ID = 1.0 mA		
RDS(on)	Static Drain-to-Source	—	_	0.60		VGS = 12V, ID = 6.5A		
	On-State Resistance	—	—	0.65	Ω	VGS = 12V, ID = 10.4A		
VGS(th)	Gate Threshold Voltage	2.5	_	4.5	V	$V_{DS} = V_{GS}$ , $I_{D} = 1.0 \text{ mA}$		
<b>g</b> fs	Forward Transconductance	3.0	—		S (7)	VDS > 15V, IDS = 6.5A ④		
IDSS	Zero Gate Voltage Drain Current	—	—	50	•	VDS = 0.8 x Max Rating,VGS = 0V		
		—	—	250	μΑ	VDS = 0.8 x Max Rating		
						VGS = 0V, TJ = 125°C		
IGSS	Gate-to-Source Leakage Forward	—	_	100	nA	VGS = 20V		
IGSS	Gate-to-Source Leakage Reverse	—	—	-100		VGS = -20V		
Qg	Total Gate Charge	—	—	150		VGS =12V, ID = 10.4A		
Qgs	Gate-to-Source Charge	—		30	nC	VDS = Max. Rating x 0.5		
Qgd	Gate-to-Drain ("Miller") Charge	—		75				
td(on)	Turn-On Delay Time	—	—	55		VDD = 300V, ID = 10.4A,		
tr	Rise Time	—	—	190	ns	RG = 2.35Ω		
td(off)	Turn-Off Delay Time	—	—	210	115			
tf	Fall Time	—	—	130				
LD	Internal Drain Inductance	—	2.0	_	nH	Measured from the drain lead, 6mm (0.25 in.) from package to center of die.		
LS	Internal Source Inductance	_	6.5			Measured from the source lead, 6mm (0.25 in.) from package to source bonding pad.		
C <sub>iss</sub>	Input Capacitance		2700	_		$V_{GS} = 0V, V_{DS} = 25V$		
C <sub>OSS</sub>	Output Capacitance	_	300		pF	f = 1.0 MHz		
C <sub>rss</sub>	Reverse Transfer Capacitance	—	61	_				

# Electrical Characteristics @ Tj = 25°C (Unless Otherwise Specified)

# **Source-Drain Diode Ratings and Characteristics**

	Parameter		Min.	Тур.	Max.	Units	Test Conditions	
IS	Continuous Source Current (E	—	_	10.4	Α	Modified MOSFET symbol showing the		
ISM	Pulse Source Current (Body I		_	41.6		integral reverse p-n junction rectifier.		
VSD	Diode Forward Voltage	—	—	1.62	V	Tj = 25°C, IS = 10.4A, VGS = 0V ④		
trr	Reverse Recovery Time		—	1200	ns	Tj = 25°C, IF = 10.4A, di/dt ≤ 100A/μs		
QRR	Reverse Recovery Charge			—	16	μC	V <sub>DD</sub> ≤ 50V ④	
ton	Forward Turn-On Time	Intrinsic turn-on time is negligible. Turn-on speed is substantially controlled by $L_S$ +						

# **Thermal Resistance**

	Parameter	Min.	Тур.	Max.	Units	Test Conditions	
RthJC	Junction-to-Case	-	—	0.83	KANE		
R <sub>thJ-PCB</sub>	Junction-to-PC board	_	TBD	_	K/W5	soldered to a copper-clad PC board	U.con

## IRHN2C50SE, IRHN7C50SE Devices

### **Radiation Characteristics**

#### **Radiation Performance of Rad Hard HEXFETs**

International Rectifier Radiation Hardened HEX-FETs are tested to verify their hardness capability. The hardness assurance program at International Rectifier uses two radiation environments.

Every manufacturing lot is tested in a low dose rate (total dose) environment per MIL-STD-750, test method 1019. International Rectifier has imposed a standard gate voltage of 12 volts per note 6 and a V<sub>DSS</sub> bias condition equal to 80% of the device rated voltage per note 7. Pre- and post-radiation limits of the devices irradiated to  $0.5 \times 10^5$  Rads (Si) and  $1 \times 10^5$  Rads (Si) are identical and are presented in Table 1, column 1, IRHN2C50SE and IRHN7C50SE, respectively. The values in Table 1 will be met for either of the two low dose rate test circuits that are used.

#### Both pre- and post-radiation performance are tested and specified using the same drive circuitry and test conditions in order to provide a direct comparison. It should be noted that at a radiation level of $1 \times 10^5$ Rads (Si), no change in limits are specified in DC parameters.

High dose rate testing may be done on a special request basis, using a dose rate up to  $1 \times 10^{12}$  Rads (Si)/Sec.

International Rectifier radiation hardened HEXFETs have been characterized in neutron and heavy ion Single Event Effects (SEE) environments. Single Event Effects characterization is shown in Table 3.

Table 1.	Low Dose Rate 6 ⑦	IRHN2C50SE	50K Rads (Si)		
	Parameter	IRHN7C50SE	100K Rads (Si)	Units	Test Conditions 10
		Min.	Max.		
BV <sub>DSS</sub>	Drain-to-Source Breakdown Voltage	600	—	v	$V_{GS} = 0V, I_D = 1.0 \text{ mA}$
V <sub>GS(th)</sub>	Gate Threshold Voltage ④	2.0	4.5	V	$VGS = V_{DS}, I_D = 1.0 \text{ mA}$
I <sub>GSS</sub>	Gate-to-Source Leakage Forward	—	100	nA	$V_{GS} = 20V$
I <sub>GSS</sub>	Gate-to-Source Leakage Reverse	—	-100		V <sub>GS</sub> = -20V
IDSS	Zero Gate Voltage Drain Current	—	50	μA	$V_{DS} = 0.8 \text{ x} \text{ Max} \text{ Rating}, V_{GS} = 0 \text{V}$
R <sub>DS(on)1</sub>	Static Drain-to-Source ④	—	0.60	Ω	VGS = 12V, I <sub>D</sub> = 6.5A
	On-State Resistance One				
V <sub>SD</sub>	Diode Forward Voltage ④	_	1.62	V	$T_{C} = 25^{\circ}C, I_{S} = 10.4A, V_{GS} = 0V$

#### Table 2. High Dose Rate ®

		1011 F	Rads (	Si)/sec	10 <sup>12</sup> F	1012 Rads (Si)/sec			
	Parameter	Min.	Тур	Max.	Min.	Тур.	Max.	Units	Test Conditions
VDSS	Drain-to-Source Voltage	—	—	480	—	—	480	V	Applied drain-to-source voltage
									during gamma-dot
IPP		—	6.4	_	—	6.4		A	Peak radiation induced photo-current
di/dt		—	—	16	—	—	2.3	A/µsec	Rate of rise of photo-current
L <sub>1</sub>		20	—	_	137	—	—	μH	Circuit inductance required to limit di/dt

#### Table 3. Single Event Effects (9)

Param	eter	Тур.	Units	Ion	LET (Si)	Fluence	Range	V <sub>DS</sub> Bias	V <sub>GS</sub> Bias	
		71			(MeV/mg/cm <sup>2</sup> )	(ions/cm <sup>2</sup> )	(µm)	(V)	(V)	00000000000
BVDS	SS	600	V	Ni	28	1 x 10⁵	~35	480 ****	v.Datasneet	4U.com

# IRHN2C50SE, IRHN7C50SE Devices

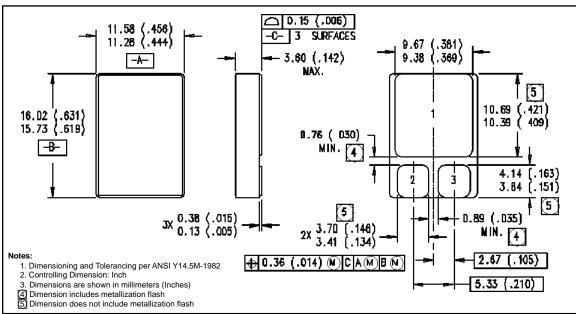
#### Repetitive Rating; Pulse width limited by maximum junction temperature. Refer to current HEXFET reliability report.

- ④ Pulse width  $\leq$  300 µs; Duty Cycle  $\leq$  2%
- ⑤ K/W = °C/W W/K = W/°C

6 Total Dose Irradiation with V<sub>GS</sub> Bias. 12 volt V<sub>GS</sub> applied and V<sub>DS</sub> = 0 during irradiation per MIL-STD-750, method 1019.

**Radiation Characteristics** 

- ⑦ Total Dose Irradiation with VDS Bias. VDS = 0.8 rated BVDSS (pre-radiation) applied and VGS = 0 during irradiation per MIL-STD-750, method 1019.
- ⑧ This test is performed using a flash x-ray source operated in the e-beam mode (energy ~2.5 MeV), 30 nsec pulse.
- (9) Process characterized by independent laboratory.
- IP All Pre-Radiation and Post-Radiation test conditions are identical to facilitate direct comparison for circuit applications.



# International

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# **Case Outline and Dimensions — SMD-1**

#### DataSheet4U.com